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Technical Compliance

Report No. ACS-E25163

The following product has been tested by us with the listed standards and found in compliance with the council EMC directive 2014/30/EU. It is demonstrative for the compliance with this EMC Directive.

Applicant : TPV Electronics (FuJian) Co., Ltd.
Rongqiao Economic and Technological Development Zone,
Fuqing City, Fujian Province, P.R. China

Product : LCD Monitor

Model No. : CS24*****; AG246***** (*=0-9,A-Z,a-z,+,-,/,\ or blank)

Brand : AOC

Test Standards :

EN 55032: 2015 (Class B) EN 55032: 2015+A11: 2020 EN 55032: 2015+A1: 2020 CISPR 32:2015+A1:2019 AS/NZS CISPR 32: 2015+A1: 2020	Electromagnetic compatibility of multimedia equipment - Emission requirements	
EN 61000-3-2: 2014, Class D EN IEC 61000-3-2:2019+A1:2021	Electromagnetic compatibility(EMC) Part 3-2:Limits-Limits for harmonic current emissions(equipment input current ≤16A per phase)	
EN 61000-3-3: 2013 EN 61000-3-3: 2013+A1:2019 EN 61000-3-3: 2013+A2:2021	Electromagnetic compatibility(EMC) Part 3-3:Limits-Limitation of voltage changes, voltage fluctuations and flicker in public low-voltage supply systems, for equipment with rated current ≤16A per phase and not subject to conditional connection.	
EN 55035: 2017 / CISPR 35: 2016 EN 55035: 2017+A11:2020	Electromagnetic compatibility of multimedia equipment — Immunity requirements	
	IEC 61000-4-2: 2008	Electrostatic Discharge
	IEC 61000-4-3: 2020	RF Field Strength Susceptibility
	IEC 61000-4-4: 2012	Electrical Fast Transients
	IEC 61000-4-5: 2014+A1:2017	Surge
	IEC 61000-4-6: 2023	Continuous Conducted Disturbance
	IEC 61000-4-8: 2009	Magnetic Field Immunity
	IEC 61000-4-11: 2020	Dips / Voltage Interruption Variation



Sunny Lu
Manager

Date : Jun.30, 2025

The technical compliance is based on a single evaluation of one sample of above mentioned products. It does not imply an assessment of the whole production and does not permit the use of the test lab. logo.